

In repatent application of

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Confirmation No. 9890

METHOD FOR MANUFACTURING SEMICONDUCTOR DEVICE AND

SEMICONDUCTOR DEVICE WITH OVERLAY MARK

AMENDMENT UNDER 37 C.F.R. §1.111

Commissioner for Patents P.O. Box 1450 Alexandria, Va. 22313-1450

Sir:

For:

In response to the Office Action mailed February 2, 2004, please amend the subject application as follows:

Amendments to the Drawings begin on page 2 of this paper and include both an attached replacement sheet and an annotated sheet showing changes.

Amendments to the claims are reflected in the listing of claims, which begins on page 4 of this paper.

Remarks begin on page 5 of this paper.

AMENDMENTS TO THE DRAWINGS:

The first set of attached sheets of drawings includes a new drawing FIG. 7 and an annotated sheet showing changes thereto. The sheet that includes new FIG. 7 replaces the original sheet including FIG. 7. In FIG. 7, a typographical error in the text of blocks S202 and S204 has been corrected. More particularly, in the text of blocks S202 and S204, the previously misspelled word "FORMATION" has been corrected. Therefore, no new matter is added by the new drawing FIG. 7.

The second set of attached sheets of drawings includes a new drawing FIG. 8 and an annotated sheet showing changes thereto. The sheet that includes new FIG. 8 replaces the original sheet including FIG. 8. In FIG. 8, reference numerals 22 and 24, which were previously interposed, have repositioned correctly. Therefore, no new matter is added by the new drawing FIG. 8.

Attachments:

Replacement Sheet Showing Drawing FIG. 7

Annotated Sheet Showing Changes to FIG. 7

Replacement Sheet Showing Drawing FIG. 8

Annotated Sheet Showing Changes to FIG. 8